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Key indicators

Single-crystal X-ray study

$T = 294$ K

Mean $\sigma(\text{C}-\text{C}) = 0.007$ Å

R factor = 0.084

wR factor = 0.189

Data-to-parameter ratio = 13.0

For details of how these key indicators were automatically derived from the article, see <http://journals.iucr.org/e>.

3-Fluorophenylboronic acid

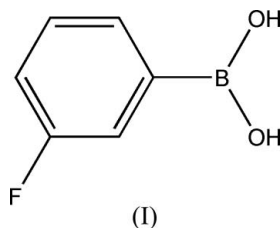
The title compound, $\text{C}_6\text{H}_5\text{BFO}_2$, is a versatile building block in organic synthesis. In the crystal structure, intermolecular $\text{O}-\text{H}\cdots\text{O}$ hydrogen bonds link the molecules into dimers, which may be effective in the stabilization of the crystal structure.

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Comment

The title compound, (I), is a versatile building block in organic synthesis and an important intermediate in the synthesis of active compounds in the agrochemical and pharmaceutical industries (Meudt *et al.*, 2002).



In the molecule of the title compound, (I) (Fig. 1), the bond lengths and angles are within normal ranges (Allen *et al.*, 1987).

As can be seen from the packing diagram (Fig. 2), intermolecular $\text{O}-\text{H}\cdots\text{O}$ hydrogen bonds (Table 2) link the molecules into dimers, which may be effective in the stabilization of the crystal structure. Dipole-dipole and van der Waals interactions are also effective in the molecular packing.

Experimental

Compound (I) was prepared according to the reported procedure of Meudt *et al.* (2002). Single crystals suitable for X-ray diffraction were

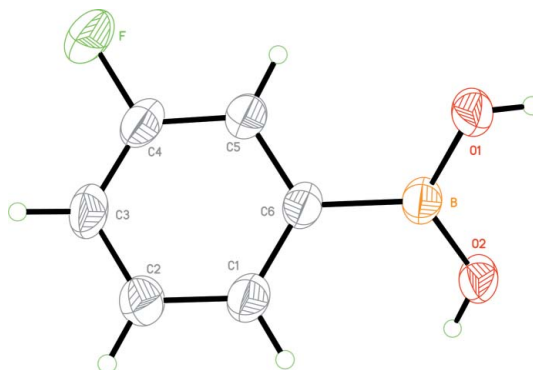


Figure 1

The molecular structure of (I), showing the atom-numbering scheme. Displacement ellipsoids are drawn at the 50% probability level.

obtained by slow evaporation of an acetonitrile (25 ml) solution of (I) (1.0 g).

Crystal data

$C_6H_6BFO_2$
 $M_r = 139.92$
 Monoclinic, $P2_1/c$
 $a = 5.7560$ (12) Å
 $b = 5.027$ (1) Å
 $c = 22.402$ (5) Å
 $\beta = 91.19$ (3)°
 $V = 648.1$ (2) Å³

$Z = 4$
 $D_x = 1.434$ Mg m⁻³
 Mo $K\alpha$ radiation
 $\mu = 0.12$ mm⁻¹
 $T = 294$ (2) K
 Block, white
 $0.30 \times 0.20 \times 0.10$ mm

Data collection

Enraf–Nonius CAD-4
 diffractometer
 $\omega/2\theta$ scans
 Absorption correction: ψ scan
 (North *et al.*, 1968)
 $T_{\min} = 0.965$, $T_{\max} = 0.988$
 1265 measured reflections

1265 independent reflections
 868 reflections with $I > 2\sigma(I)$
 $\theta_{\max} = 26.0^\circ$
 3 standard reflections
 frequency: 120 min
 intensity decay: none

Refinement

Refinement on F^2
 $R[F^2 > 2\sigma(F^2)] = 0.084$
 $wR(F^2) = 0.189$
 $S = 0.97$
 1265 reflections
 97 parameters
 H atoms treated by a mixture of
 independent and constrained
 refinement

$w = 1/[\sigma^2(F_o^2) + (0.03P)^2 + 2P]$
 where $P = (F_o^2 + 2F_c^2)/3$
 $(\Delta/\sigma)_{\max} < 0.001$
 $\Delta\rho_{\max} = 0.23$ e Å⁻³
 $\Delta\rho_{\min} = -0.21$ e Å⁻³

Table 1

Hydrogen-bond geometry (Å, °).

$D-H\cdots A$	$D-H$	$H\cdots A$	$D\cdots A$	$D-H\cdots A$
O1–H1 ⁱ ···O2 ⁱ	0.85 (3)	2.06 (4)	2.796 (5)	144 (4)
O2–H2 ⁱ ···O1 ⁱⁱ	0.86 (3)	2.08 (3)	2.831 (5)	145 (4)

Symmetry codes: (i) $-x, -y, -z$; (ii) $x, y + 1, z$.

The H atoms of OH groups were located in difference syntheses and refined [O–H = 0.851 (19)–0.855 (19) Å, with $U_{\text{iso}}(\text{H}) = 1.2U_{\text{eq}}(\text{O})$]. The remaining H atoms were positioned geometrically,

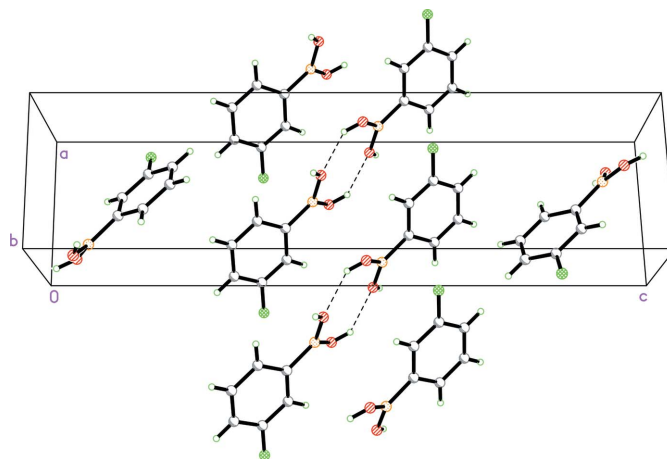


Figure 2

A packing diagram of (I). Hydrogen bonds are shown as dashed lines.

with C–H = 0.93 Å for aromatic H atoms, and constrained to ride on their parent atoms, with $U_{\text{iso}}(\text{H}) = 1.2U_{\text{eq}}(\text{C})$.

Data collection: *CAD-4 Software* (Enraf–Nonius, 1985); cell refinement: *CAD-4 Software*; data reduction: *XCAD4* (Harms & Wocadlo, 1995); program(s) used to solve structure: *SHELXS97* (Sheldrick, 1997); program(s) used to refine structure: *SHELXL97* (Sheldrick, 1997); molecular graphics: *SHELXTL* (Bruker, 2000); software used to prepare material for publication: *SHELXTL*.

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